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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#28
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Application Serial Number 09/292,132
Filing Date April 14, 1999
Inventor Salman Akram et al.
Assignee Micron Technology, Inc.
Group Art Number 2812
Examiner S. Mulpuri
Attorney's Docket No. MI22-1171
Title: Methods of Forming a Transistor Gate

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT


Reference -- See Attached Form PTO-1449

The attached form PTO-1449 is submitted in compliance with 37 CFR §1.56. No admission is made regarding whether the submitted reference is prior art.

Respectfully submitted,

Dated: 1-02-03

Attorney:


D. Brent Kenady
Reg. #40,045

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LIST OF ARTS CITED BY APPLICANT
(Use separate sheet if necessary)

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PATENT AND TRADEMARK OFFICE

ATTY. DOCKET NO.
MI22-1171

SERIAL NO.
09/292,132

APPLICANT
Salman Akram et al.

FILING DATE
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GROUP
2812

U.S. PATENT DOCUMENTS

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
	AL							
	AM							
	AN							
	AO							
	AP							

OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)

	AR		Wolf, Ph.D., Stanley, "Silicon Processing for the VLSI Era - Volume 2: Process Integration," ©1990 Lattice Press, pages 212-213.
	AS		
	AT		

EXAMINER

DATE CONSIDERED

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.